



Form PTQ-1449 (REV. 10-97) (modified)	ATTY. DOCKET NO. MCRO 144-3	SERIAL NO. 10/774,742
List of Patents and Publications For Applicant's Information Disclosure Statement	APPLICANT Trung T. Doan et al	
(Use several sheets if necessary)	FILING DATE 02/09/04	GROUP 2827

#### U.S. PATENT DOCUMENTS

EXAM. INIT.	REF. DES.	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
CR	A1	3,106,489	10/08/63	Lepselter	117	217	12/09/60
CR	A2	4,502,209	03/05/85	Eisenberg et al	29	589	08/31/83
CR	A3	4,784,973	11/15/88	Stevens et al	437	200	08/24/87
CR	A4	4,814,854	03/21/89	Tigelaar et al	357	67	12/05/86
CR	A5	4,829,363	05/09/89	Thomas et al	357	71	07/25/88
CR	A6	4,910,580	03/20/90	Kuecher et al	357	71	08/01/88
CR	A7	4,937,652	06/26/90	Okumura et al	357	68	09/30/88
CR	A8	4,994,410	02/19/91	Sun et al	437	192	02/16/90
CR	A9	5,134,460	07/28/92	Brady et al	357	71	11/02/90
CR	A10	5,182,420	01/26/93	Steitz et al	174	52.4	04/09/90
CR	A11	5,317,187	05/31/94	Hindman et al	257	659	02/16/93
CR	A12	5,372,974	12/31/94	Doan et al	437	240	03/19/93
CR	A13	5,475,267	12/12/95	Ishi et al	257	752	12/08/94
CR	A14	4,870,031	09/26/89	Sugahara et al	437	82	09/30/87
CR	A15	5,284,804	02/08/94	Moslehi	437	228	12/31/91
CR	A16	6,690,044 B1	02/10/04	Doan et al	257	258	05/20/97
CR	A17	5,291,058	03/1/94	Samata et al	257	751	07/30/92
CR	A18	5,155,564	10/13/92	Hishida et al	257	410	11/21/90
CR	A19	5,412,245	05/02/95	Favreau	257	751	05/23/94
CR	A20	5,442,226	8/15/95	Maeda et al	257	751	04/26/93



## FOREIGN PATENT DOCUMENTS

EXAM. INIT.	REF. DES.	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION
CR	B1	5632732	04/2/81	Japan	437	240	Abstract (Yes) Patent (No)

## OTHER ART

(Author, Title, Journal, Volume, Pertinent Pages, &amp; Date)

CR	C1	Wolfe et al., Vol. 1, Silicon Processing for the VLSI Era, Lattice Press, 1986, pp0181-191.

EXAMINER *Christy Garacek* DATE CONSIDERED 8/18/05

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Information Disclosure Statement--PTO-1449 (Modified)